	Hits	Search Text	DBs	Time Stamp
1	6	((mask?less) (without near2 mask) mask) near3 pattern same (electrons electron particle particles cell cells) and substrate and stress near2 dielectric and dielectric with (interconnect conductor conductive conduction)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2007/01/06 16:42
2		electron particle		2007/01/06 16:46
3	6	(interconnect conductor conductive conduction)	IICDAT.	2007/01/06 16:47
4	29	and dielectric with (interconnect conductor	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2007/01/06 16:48
5	0	(interconnect conduct\$4)).clm.	•	2007/01/06 17:37
6		(maskless with lithograph\$3 and (cell cells) with expose\$4 and dielectric with (interconnect conduct\$4)).clm.		2007/01/06 17:38

	Hits	Search Text	DBs	Time Stamp
7	0	(direct adj write with lithograph\$3 and (cell cells) with expose\$4 and dielectric with (interconnect conduct\$4)).clm.	US-PGPUB; USPAT	2007/01/06 17:38
8	0	(direct adj write and lithograph\$3 and (cell cells) with expose\$4 and dielectric with (interconnect conduct\$4)).clm.	US-PGPUB; USPAT	2007/01/06 <sup>.</sup> 17:39
9		(direct adj write and lithograph\$3 and (cell cells) with expose\$4).clm.	US-PGPUB; USPAT	2007/01/06 17:39
10	0	(direct adj write and lithograph\$3 and (cell cells) and expose\$4).clm.	US-PGPUB; USPAT	2007/01/06 17:39
11	85	(direct adj write and lithograph\$3).clm.	US-PGPUB; USPAT	2007/01/06 17:45